



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Application No.:	10/572,799	Confirm. No.:	4919
Filing Date:	March 22, 2006	Examiner:	Slutsker, Julia
First Inventor:	Dimitri LEDERER	Art Unit:	2891
Attorney No.:	LEDE3001/JJC/JDG	Customer No.:	23364
For:	METHOD OF MANUFACTURING A MULTILAYER SEMICONDUCTOR STRUCTURE WITH REDUCED OHMIC LOSSES		

AMENDMENT  
AND  
REPLY TO OFFICE ACTION  
OF NOVEMBER 7, 2008

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

This is responsive to the outstanding Office Action in the above-identified application. In view of the following remarks, reconsideration of the application is respectfully requested.

Applicant includes herewith a Petition for Extension of Time (Two-Months) and necessary fees to extend the time for response to April 7, 2009. The present amendment is timely filed.

In the Claims

The claims are amended as shown on the following pages under the heading AMENDMENT TO THE CLAIMS. The list shows the status of all claims presently in the application and is intended to supersede all prior versions of the claims in the application. Any cancellation of claims is made without prejudice or disclaimer.